

# Linear and nonlinear tunable optical properties of intersubband transitions in GaN/AlN quantum dots in presence and absence of wetting layer

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In this study we have performed a numerical approach to investigate the optical properties of GaN/AlN quantum dots (QDs). We have used nice homemade finite element method (FEM) codes to solve the Schrödinger equation, in presence and absence of wetting layer. The optical properties of both well-known, truncated pyramids-shaped, wurtzite (WZ) and zinc blende (ZB) QDs have been investigated. It is demonstrated, there is slight amount of difference between all orders of absorption coefficients and relative refractive index changes (RRIC) for both structures. The effect of relaxation rate studied as well. Overlay it is shown that the optical properties ZB/WZ QDs could be engineered in well-manner.

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## 1 INTRODUCTION

During the last few years, semiconductor QD heterostructures have been subject of extensive interest due to their advantages over quantum wells and wires, ultimate three-dimensional (3D) confinement structures of carriers, promising efficient lasers and optical amplifiers as well as possible applications for memory storage and quantum computing [1]. Owing to the lattice mismatch between layers and the base material, the strain effect drives the QDs towards 3D islands. The unconverted QD material is called wetting layer [2]. Semiconductor QDs are potentially ideal for achieving large arrays of reproducible entangled photon generators as they allow the generation of requested photons [3, 4] with no dependence to probabilistic processes [5]. Recently, in state of the art treatise it is reported that QDs arrays can be employed to obtain areas with up to 15% polarization entangled photon emitter along with fidelities as high as  $0.721 \pm 0.043$  [6]. Moreover, a record source efficiency of 0.72, combined with pure single-photon emission is demonstrated by J. Cluden *et al.* [7] by making use of a QD in a photonic nanowire under optical pumping which it would be potentially a high efficient QD based single photon source. E. Stinaff *et al.* [8] reported that asymmetric pair of InAs QDs tuned into resonance by applying an electrical field which it leads to the formation of a coherent molecular wavefunction by a single hole. Also they have found that coulomb interactions shift the molecular resonance of charged exciton with respect to the single charge, enabling the QDs light-induced coupling. Theoretically, Michael *et al.* [9] explored the slowdown of optical pulses due to the quantum coherence effects for an active material consisting of double InGaAs-based

QD molecules. Also the dependencies of slowdown, the shape of propagating probe pulses on lattice temperature and drive intensities have been explored as well. Ramanathan *et al.* [10] have conducted an experimental research on the effect of tunnel coupling on the Quantum-Confined Stark Effect for excitons in the coupled InAs/GaAs QDs, precisely they demonstrated that any decrease of dots' separation by the barrier leads to a remarkable escalation on zero-field dipole moments and polarizability. The transmission coefficient and group index properties of the probe field in a four-level QD molecule is being investigated in literature where the author found that the tunnel coupling plays a very important role in realizing the transmission coefficient of the probe field [11]. Moreover the Second harmonic generation and optical rectification [12] as well as the impact of Woods-Saxon potential on InAs/GaAs QDs [13] is explored as well.

Particularly, group III-nitride materials are very appropriate for implementation in high-power, high frequency, and high-temperature electronics, to mention but a few [14]. It is worth mentioning that these materials could be crystallize either with wurtzite (WZ) crystal structure which is a thermodynamically stable configuration or with zinc-blende (ZB) structure which is modified meta-stably [15].

It is shown that under particular growth conditions, the strain relaxation of WZ GaN grown by MBE on AlN occurs through 3D islanding after deposition of a few 2D monolayers. The characteristics of this growth mode are known as Stranski-

Krastanov (SK). In this mode the deposition of a strained wetting layer is followed by elastic relaxation through 3D islanding which results in free surface formation [16]. So far various materials have been developed by SK under compressive stress, such as InAs /GaAs [17], InP/GaInP [18] or SiGe/Si [19]. In addition, single polar GaN/AlN QDs have been fabricated by metal-organic chemical vapor deposition (MOCVD) method [20]. Indeed, GaN/AlN QDs with wide band gap have attracted remarkable attention for potential application in optical, optoelectronic, and electronic devices [21]; such as developing single electron transistors [22], ultraviolet sources [23] as well as detectors [24]. More accurately, GaN and AlN form a continuous alloy system whose direct band-gaps exhibit wide profile (3.4 and 6.2 eV [25]–[27], respectively) and owing to low dielectric constants and large effective masses, consistently present strong excitonic binding energies (26 meV for GaN) [28]. The lattice mismatch is about 2.4% between GaN and AlN [29].

P. Lefebvre *et al.* [28] illustrated that in the grown GaN/AlN QDs along the (0001) axis in the WZ phase, the optical characteristics are dominated by huge on-axis internal electric fields, leading to a very low oscillator strength and complex dynamical behavior. Moreover, The cathodoluminescence investigations of GaN/AlN QD optical emissions in order to assess the reliability of the depth-resolved cathodoluminescence technique in revealing QD-related optical emissions as well as to distinguish between layers with different nominal GaN coverage's were reported by Salvati *et al.* [30]. A microphotoluminescence study of single GaN/AlN QDs in nanowires is presented by Renard *et al.* [31] and they observed low excitation power, single exciton lines with full width at half-maximum as narrow as 1 meV. Also it is demonstrated that investigating the excitation power dependence of the emission give permission to identify the biexciton transitions. V. A. Fonoberov *et al.* [32] have worked both theoretically and experimentally on the excitonic optical properties as well as have found the discrepancies between the radiative lifetime for different sizes of WZ and ZB QDs. N. Skoulidis *et al.* have studied the wavefunctions and the oscillator strength both close to the fundamental gap [33].

In this paper we will report the optical properties of both truncated cone shaped WZ and ZB GaN/AlN QDs. Indeed, the linear, second and third order nonlinear susceptibilities will be employed to investigate the linear and nonlinear absorption coefficient as well as relative refractive index changes both in the presence and absence of wetting layer. The strain energy in QDs structure can affect the energy eigenvalues, envelope functions, therefore it will profound influence on the optical properties of QDs. Nevertheless the strain effects can be compensated using strain compensation layers as demonstrated by Nuntawong *et al.* [34, 35] The strain effect has also been compensated by Zhao *et al.* [36] and Park *et al.* [37] in InGa<sub>1-x</sub>N/AlGa<sub>x</sub>N and InGa<sub>1-x</sub>N/InGa<sub>x</sub>N quantum wells, respectively. Therefore we avoid considering the strain in our computational experiments based on mentioned references.

## 2 MODEL AND EQUATIONS

In our modeling, confined electrons on the self-assembled GaN/AlN QD structures with and without wetting layers are examined based on the  $\vec{k}\vec{p}$  method. In this case we will use the presented mythology in reference [2] as well used by reference [38]. This model illustrates interpretations for states with arbitrary kinetic energy in the quantum well (QW) wetting layer. States of electrons for single QD/QW wetting layer system will asymptotically approach either 'pure' QW states far from the QD, or zero if the state is a 'true' state of QD [2].

In the following, a model procedure will be presented that allows us to determine energy eigenvalue and associated wavefunction of any cylindrically symmetric QDs structure in presence/absence of wetting layers. The starting point is the 1-band Schrödinger equation in the effective mass approximation:

$$-\frac{\hbar^2}{2} \nabla \left( \frac{1}{m_e(\vec{x})} \nabla \psi(\vec{x}) \right) + V_e(\vec{x}) \psi(\vec{x}) = E \psi(\vec{x}), \quad (1)$$

Where  $\hbar$ ,  $m_e(\vec{x})$ ,  $V_e(\vec{x})$ ,  $E$  and  $\psi(\vec{x})$  are Planck's constant divided by  $2\pi$ , the electron effective mass, the band-edge potential energy, the energy eigenvalue and electron envelope function, respectively. According to the assumption that we have cylindrical symmetry so  $\vec{x} = (z, r\phi)$ ,  $V_e(\vec{x}) = V_e(zr)$ , and  $m_e(\vec{x}) = m_e(z, r)$ . Where  $z$  and  $r$  are the axial and radial coordinates, and  $\phi$  is the azimuthal angle ranging from  $0 - 2\pi$ . Cylindrical symmetry allows us to use the separation of variables technique as follows for the envelop function:

$$\psi(\vec{x}) = \chi(z, r) \Phi(\phi), \quad (2)$$

By using some simple and straight forward mathematical treatment Eq. (1) becomes:

$$\begin{aligned} & -\frac{\hbar^2}{2} \frac{\partial}{\partial z} \left( \frac{1}{m_e(z, r)} \frac{\partial \chi(z, r)}{\partial z} \right) \Phi(\phi) \\ & - \frac{\hbar^2}{2r} \frac{\partial}{\partial r} \left( \frac{r}{m_e(z, r)} \frac{\partial \chi(z, r)}{\partial r} \right) \Phi(\phi) \\ & - \frac{\hbar^2 \chi(z, r)}{2m_e(z, r) r^2} \frac{\partial^2 \Phi}{\partial \phi^2} + V_e(z, r) \chi(z, r) \Phi(\phi) \\ & = E \chi(z, r) \Phi(\phi) \end{aligned} \quad (3)$$

For the aim of simplification we divide both side of Eq. (3) by  $\frac{\Phi(\phi)\chi(z, r)}{m_e(z, r)r^2}$ , therefore Eq. (3) can be rearrange as:

$$\begin{aligned} & \frac{m_e(z, r) r^2}{\chi(z, r)} \left( -\frac{\hbar^2}{2} \frac{\partial}{\partial z} \left( \frac{1}{m_e(z, r)} \frac{\partial \chi(z, r)}{\partial z} \right) \right. \\ & \left. - \frac{\hbar^2}{2r} \frac{\partial}{\partial r} \left( \frac{r}{m_e(z, r)} \frac{\partial \chi(z, r)}{\partial r} \right) \right) \\ & + m_e(z, r) r^2 (V_e(z, r) - E) \\ & = -\frac{\hbar^2}{2} \frac{\partial^2 \Phi}{\partial \phi^2} \frac{1}{\Phi(\phi)} \equiv -\frac{\hbar^2}{2} l^2 \end{aligned} \quad (4)$$

An immediate solution for last part of Eq. (4) could be proposed as:

$$\Phi(\phi) = e^{il\phi}, \quad (5)$$

Where  $l$  is a separation constant. As the envelope function must be single-valued under  $2\pi$  rotation. In our modeling  $l$  can takes values of  $l = 0, \pm 1, \pm 2, \dots$

$$-\frac{\hbar^2}{2} \frac{\partial}{\partial z} \left( \frac{1}{m_e(z,r)} \frac{\partial \chi_l}{\partial z} \right) - \frac{\hbar^2}{2r} \frac{\partial}{\partial r} \left( \frac{r}{m_e(z,r)} \frac{\partial \chi_l}{\partial r} \right) + \left( \frac{\hbar^2 l^2}{2m_e(z,r)r^2} + V_e(z,r) \right) \chi_l = E \chi_l \quad (6)$$

Eq. (6) has the geeneral form of:

$$\nabla(-c \nabla \chi_l) + \alpha \chi_l + \beta \nabla \chi_l = E \chi_l \quad (7)$$

With  $\beta = -\frac{\hbar^2}{2m_e} \frac{1}{r}$ ,  $\alpha = \frac{4\hbar^2 l^2}{m_e r^2} + V$ , and  $c = \frac{\hbar^2}{2m_e}$ .

Both original and simplified forms of Schrödinger equation, contain discontinuous coefficients under spatial derivative operators, owing to different material charactrsits of GaN and AlN. Physically, in the modeling procedure the following boundary condition must be satisfied.

$$\psi \in C(Q), \text{ and } \left( -\frac{1}{m_e \nabla \psi(\vec{x})} \cdot \vec{n} \right)_{QD/wettinglayer} = \left( -\frac{1}{m_e \nabla \psi(\vec{x})} \cdot \vec{n} \right)_{matrixes} \quad (8)$$

Which  $m_e$  is the electron effective mass which has specific values for every material,  $n$  is the outward normal vector,  $C$  is the class of continuous function,  $Q$  is the spatial  $(z, r)$  domain of interest. The effective mass potential is considered to be constant for every material. The envelope function solution for a stepwise constant effective mass potential is:

$$\psi_{nk}(z, r, \phi) = A_{nk} Z_{nk}(z) J_n(kr) e^{i l \phi} \quad (9)$$

$Z_{nk}$  could be obtained from the solution of

$$\frac{\partial}{\partial z} \left( \frac{1}{m_e(z)} \frac{\partial Z_{nk}}{\partial z} \right) + \frac{2}{\hbar^2} \left( E - v_e(z) - \frac{\hbar^2 k^2}{2m_e(z)} \right) Z_{nk} = 0 \quad (10)$$

$\psi_{nk}$  must satisfy the following condition:

$$\begin{cases} \frac{\partial \psi_{nk}}{\partial r} - \frac{K(J_{n-1}(kr) - J_{n+1}(kr))}{2J_n(kr)} \psi_{nk} = 0, & \text{if } J_n(kr) \neq 0 \\ \psi_{nk} = 0, & \text{if } J_n = 0 \end{cases} \quad (11)$$

Inasmuch as

$$J_{n-1}(y) - J_{n+1}(y) = \frac{2\partial J_n(y)}{\partial y} \quad (12)$$

Prior to proposing a solution for simplified Schrödinger equation, appropriate boundary conditions must be supplemented. In order to employ adequate boundary conditions we consider the  $z$  axis to be perpendicular to wetting layer plane also  $r$  axis is chosen to be on wetting layer plane (Figure 1). As far as we are interested in the confined electronic states, the Dirichlet boundary condition ( $\psi = 0$ ) is imposed for boundaries 1 and 3. In order to satisfy Eq. (8) for the interior boundaries, the continuity condition

$$\left( -\frac{1}{m_e \nabla \psi(\vec{x})} \cdot \vec{n} \right)_{GaN} = \left( -\frac{1}{m_e \nabla \psi(\vec{x})} \cdot \vec{n} \right)_{AlN}$$

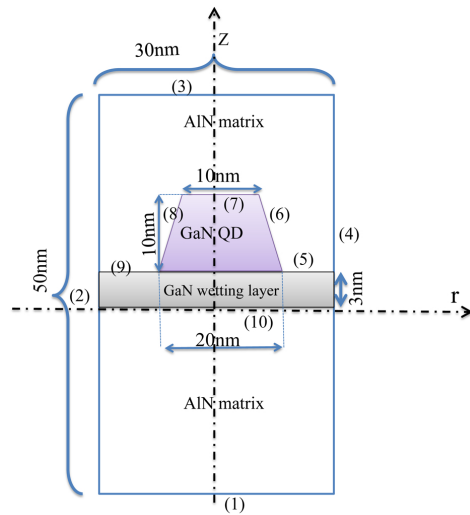


FIG. 1 The Geometry of and numbered boundary of GaN/AlN QDs.

is applied for boundaries 5, 6, 7, 8, 9, and 10. For relatively large values of  $r$ , the envelope function for GaN/AlN QDs approaches asymptotically either the envelope function for the pure wetting layer problem or zero if the state is true QD state. Consequently Eq. (11) could be considered for 2 and 4 boundaries. Because it is presumed that boundary 2 and 4 are located at relatively large values of  $r$ , far from the QD region. The chosen values, shown in Figure 1. Satisfy this assumption.

It is strightfoward to mention that Eq. (7) is a partial diferentail equaion (PDE). We employ this fact that the presented formulate for QD system have to be investigated numerically. In this regard we developed our homemade codes using finite element method (FEM) to perform the numerical solution for the QD system with given boundary conditions. In our numerical approach we have considered truncated pyramids QD both in presence of wetting layer for ZB and WZ structure. The gremetry and dimension of the GaN/AlN is considered according to Figure 1.

To investigate the optical properties we have considered a linear  $x$ -polarized electric field propagating along  $z$  direction as:

$$\vec{E}(z, t) = E_0 i e^{i(kz - \omega t)} + CC \quad (13)$$

Where  $\omega$  is the angular frequency,  $k = \frac{N\omega}{c}$  is the propagation constant,  $N$  is the complex index of refraction consist of real and imaginary parts ( $N = n_R + in_i$ ). By making use of well-known nonlinear optics formalism the complex refractive index in the form of effective susceptibility will be as follows:

$$N = \sqrt{1 + \chi_{eff}} \approx 1 + \frac{1}{2} \chi_{eff} \quad (14)$$

Where the effective susceptibility is constructed from first, second and third order susceptibilities respectively and it is defines as:

$$\chi_{eff} = \chi^1 + \chi^2 \vec{E} + \chi^3 \vec{E}^2 \quad (15)$$

The relative refractive index changes (RRIC's) and absorption

coefficients (AC's) are given by:

$$\begin{aligned} \frac{\Delta n}{n} &= \frac{1}{2} Re \left( \frac{\chi_{eff}}{n_r} \right) = \frac{1}{2n_r} RE \left( \chi^1 + \chi^2 \tilde{E} + \chi^3 \tilde{E}^2 \right) \\ &= \frac{\Delta n^{(1)}}{n} + \frac{\Delta n^{(2)}}{n} + \frac{\Delta n^{(3)}}{n} \end{aligned} \quad (16)$$

And

$$\alpha = \frac{2n_i \omega}{c} = \omega \sqrt{\mu/\epsilon_R} \text{Im}(\epsilon_0 \chi_{eff}) = \alpha^{(1)} + \alpha^{(2)} + \alpha^{(3)} \quad (17)$$

The susceptibilities are obtained by solving the density matrix method and perturbation theory in steady state for the QD system. The first, second, and third orders of susceptibility will be obtained as:

$$\begin{aligned} \chi^{(1)}(\omega) &= \frac{N}{\epsilon_0 \hbar} \left\{ M_{21}^2 \left[ \frac{1}{\omega_{21} - \omega - i\gamma_{21}} + \frac{1}{\omega_{21} + \omega + i\gamma_{21}} \right] \right. \\ &\quad \left. + M_{31}^2 \left[ \frac{1}{\omega_{31} - \omega - i\gamma_{31}} + \frac{1}{\omega_{31} + \omega + i\gamma_{31}} \right] \right\} \end{aligned} \quad (18)$$

$$\begin{aligned} \chi^{(2)}(\omega) &= \frac{N}{\epsilon_0 \hbar^2} \sum_{n,m=1}^3 \mu_{1n} \mu_{nm} \mu_{m1} \\ &\left\{ \frac{(\omega_{m1} - i\gamma_{m1}) [(\omega_{n1} + \omega_{nm}) + i(\gamma_{n1} - \gamma_{nm})]}{[(\omega_{m1} - i\gamma_{m1})^2 - \omega^2] (\omega_{n1} - i\gamma_{n1}) (\omega_{nm} + i\gamma_{nm})} \right. \\ &\quad \left. + \frac{(\omega_{n1} + i\gamma_{n1}) [(\omega_{m1} + \omega_{mn}) + i(\gamma_{m1} - \gamma_{mn})]}{[(\omega_{n1} + i\gamma_{n1})^2 - \omega^2] (\omega_{m1} + i\gamma_{m1}) (\omega_{mn} - i\gamma_{mn})} \right\} \end{aligned} \quad (19)$$

And

$$\begin{aligned} \chi^3 &= \frac{6N}{\epsilon_0 \hbar^3} \sum_{nmv=1}^3 \mu_{1v} \mu_{vn} \mu_{nm} \mu_{m1} \\ &\left\{ \frac{1}{[(\omega_{v1} - \omega) - i\gamma_{v1}] [\omega_{n1} - i\gamma_{n1}] [(\omega_{m1} - \omega) - i\gamma_{m1}]} \right. \\ &\quad + \frac{1}{[(\omega_{nv} - \omega) - i\gamma_{nv}]} \\ &\quad \cdot \left[ \frac{1}{[\omega_{mv} - i\gamma_{mv}] [(\omega_{v1} + \omega) + i\gamma_{v1}]} \right. \\ &\quad \left. + \frac{1}{[\omega_{vm} + i\gamma_{vm}] [(\omega_{m1} - \omega) - i\gamma_{m1}]} \right] \\ &\quad + \frac{1}{[(\omega_{mn} - \omega) - i\gamma_{mn}] [(\omega_{n1} + i\gamma_{n1}) [(\omega_{v1} + \omega) + i\gamma_{v1}]} \\ &\quad + \frac{1}{[(\omega_{vn} + \omega) + i\gamma_{vn}] [\omega_{n1} - i\gamma_{n1}] [(\omega_{m1} - \omega) - i\gamma_{m1}]} \\ &\quad + \frac{1}{[(\omega_{nm} + \omega) + i\gamma_{nm}]} \\ &\quad \cdot \left[ \frac{1}{[\omega_{mv} - i\gamma_{mv}] [(\omega_{v1} + \omega) + i\gamma_{v1}]} \right. \\ &\quad \left. + \frac{1}{[\omega_{mv} + i\gamma_{mv}] [(\omega_{m1} - \omega) - i\gamma_{m1}]} \right] \\ &\quad \left. + \frac{1}{[(\omega_{m1} + \omega) + i\gamma_{m1}] [(\omega_{n1} + i\gamma_{n1}) [(\omega_{v1} + \omega) + i\gamma_{v1}]} \right\} \end{aligned} \quad (20)$$

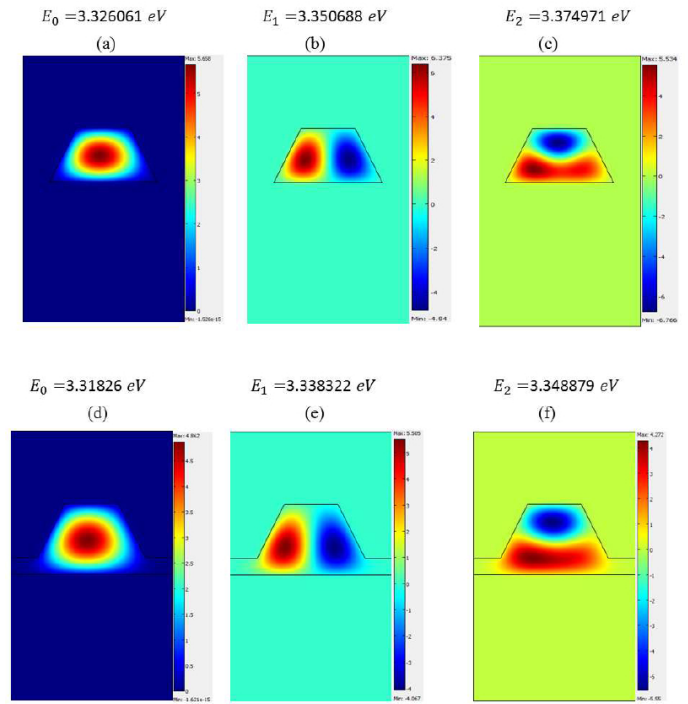


Fig 2

FIG. 2 The envelope function of GaN/AlN QDs (a) without wetting layer (b) with wetting layer (thickness = 3 nm) plotted against z and r coordinates.

### 3 RESULTS AND DISCUSSION

The characteristics of GaN/AlN QDs are set according to Table 1. To obtain the numerical results for different orders of susceptibility, the following parameters have been used: carrier density  $N = 3 \times 10^{22}$  atoms/cm<sup>2</sup> [38], vacuum permittivity  $\epsilon_0 = 8.85 \times 10^{-12}$ , relaxation rate  $\gamma = 5 \times 10^{12}$  s<sup>-1</sup> [38], speed of light in vacuum  $c = 3 \times 10^8$ , transition frequencies  $\hbar\omega_{21} = E_2 - E_1$  (as output of numerical simulation), and transition dipole moments  $\mu_{ji} = \langle \psi_j | -er | \psi_i \rangle$  (e.g.  $\mu_{21} = \langle \psi_2 | -er | \psi_1 \rangle$ ) which is calculated by using numerical envelope function and homemade codes of Simpson integration method which is written in Matlab.

As it is mentioned previously, Figure 1 shows the geometry and the dimension of GaN/AlN QDs in the modeling procedure.

Figure 2 shows the envelope function for 3 states below the potential barrier is considered. These three subbands do not represent three different subbands in the usual sense, i.e. corresponding to 1, 2, and 3 nodes along the z direction. Figure 2(a)-(c) and Figure 2(d)-(f) illustrate the GaN/AlN QDs without and with wetting layer respectively. The thickness of wetting layer is set as 3 nm [38]. The energy eigenvalues are shown above each state. The presence of wetting layer in all subbands reduces the amount of energy eigenvalue ranging from 0.01 to 0.03 eV. Moreover in presence of wetting layer, part of the envelope function shares with wetting layer however the general localization does changes. According to our expectation, the envelope function has the biggest value at the center of the QD while it decays exponentially to zero for both

	GaN		AlN	
Phase	wurtzite	zinc blende	wurtzite	zinc blende
effective mass ( $m_{electron}$ )	$0.20 \pm 0.02$ [39]	0.193 [40]	$0.29 - 0.45$ [41]	0.316 [40]
band gap (eV)	3.50 [39]	3.3 [42]-[44]	$6.0 - 6.3$ [45]	5.34 [46]

TABLE 1 Physical parameters Wurtzite and Zinc Blende GaN/AlN Quantum dots.

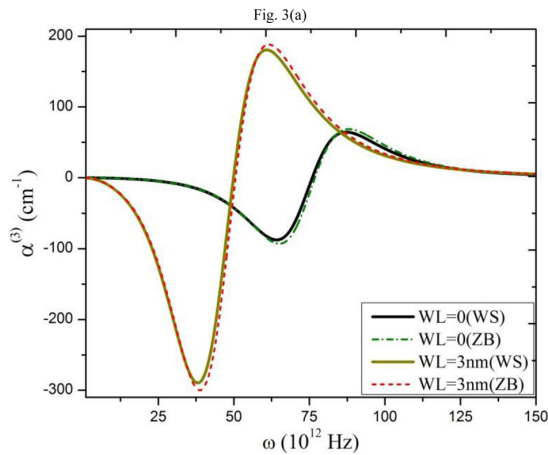
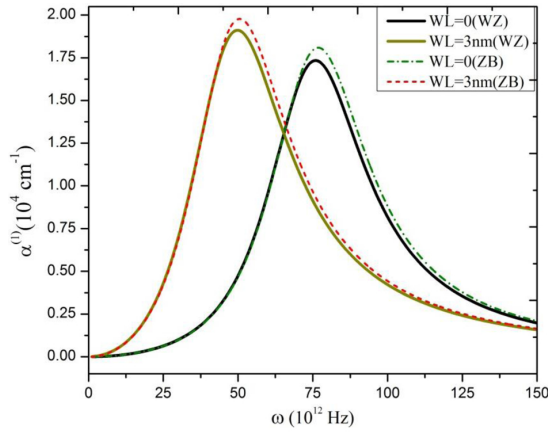


Fig. 3(b)

FIG. 3 The (a) first order, (b) third order absorption coefficients for ZB and WZ GN/AlN QDs with (solid lines) and without wetting layer (dashed and dash-dotted lines). The size of wetting layer set as 3nm and the relaxation rates chosen to be  $\gamma_{12} = \gamma_{13} = \gamma_{23} = \gamma = 5 \times 10^{12}$  and  $\gamma_{11} = \gamma_{22} = \gamma_{33} = 2\gamma$  for all curves. For ZB case, the dipole moments without wetting layer are as calculated as  $\mu_{12} = \mu_{21} = 0.0026 \times 10^{-26}$ ,  $\mu_{13} = \mu_{31} = 0.2857 \times 10^{-27}$ ,  $\mu_{23} = \mu_{32} = 0.0002 \times 10^{-27}$ ,  $\mu_{11} = 0.493 \times 10^{-26}$ ,  $\mu_{22} = 0.486 \times 10^{-26}$ ,  $\mu_{33} = 0.4947 \times 10^{-26}$  and with wetting layer being  $\mu_{12} = \mu_{21} = 0.0087 \times 10^{-26}$ ,  $\mu_{13} = \mu_{31} = 0.3775 \times 10^{-27}$ ,  $\mu_{23} = \mu_{32} = 0.0033 \times 10^{-27}$ ,  $\mu_{11} = 0.4666 \times 10^{-26}$ ,  $\mu_{22} = 0.4532 \times 10^{-26}$ ,  $\mu_{33} = 0.4723 \times 10^{-26}$ . For WZ case, the dipole moments without wetting layer are calculated as  $\mu_{12} = \mu_{21} = 0.0024 \times 10^{-26}$ ,  $\mu_{13} = \mu_{31} = 0.2814 \times 10^{-27}$ ,  $\mu_{23} = \mu_{32} = 0.0001 \times 10^{-27}$ ,  $\mu_{11} = 0.493 \times 10^{-26}$ ,  $\mu_{22} = 0.4861 \times 10^{-26}$ ,  $\mu_{33} = 0.4947 \times 10^{-26}$  and with wetting layer being  $\mu_{12} = \mu_{21} = 0.0082 \times 10^{-26}$ ,  $\mu_{13} = \mu_{31} = 0.3742 \times 10^{-27}$ ,  $\mu_{23} = \mu_{32} = 0.0034 \times 10^{-27}$ ,  $\mu_{11} = 0.4667 \times 10^{-26}$ ,  $\mu_{22} = 0.4534 \times 10^{-26}$ ,  $\mu_{33} = 0.4723 \times 10^{-26}$ .

in presence and absence of wetting layer (Figure 2(a),(d)). The peak of envelop function for ground state without wetting layer is about  $max = 5.658$  (Figure 2(a)) while in the presence of wetting layer it dramatically reduces to be  $max = 4.862$ . As Figure 2(b),(e) depict the first excited state consists of a valley and a peak. The amplitude of the peak and the valley without wetting layer is  $max = 6.375$  and  $min = -4.84$

respectively while in presence of wetting layer these values change to be  $max = 5.565$  and  $min = -4.067$  respectively. Also the amount of energy eigenvalue is about 0.02 eV smaller in presence of wetting layer. Figure 2(c),(f) shows the second excited state. This state has one valley on the top and a doublet peaks on bottom. The amount of the peak and valley is about  $max = 5.34$  and  $min = -6.766$  in absence of wetting layer as Figure 2(c) depicts. Figure 2(f) shows the second excited state in presence of wetting layer. The significant difference appears for the doublet bottom peaks where they merge to construct a single peak which is mainly located at the left side of the QD. The amount of the peak and valley is about  $max = 4.272$  and  $min = -5.55$ . To be more precise, Figure 2(f) reveals that the right peak moves toward the left side in presence of wetting layer, as the red dark area in Figure 2(f) shows that the concentration of envelope function move to left side. Generally the envelop function in presence of wetting layer has bigger FWHM simultaneously the peaks takes smaller values.

We have used Eqs. (16) and (17), to investigate the optical properties of GaN/AlN QDs. Figure 3 shows the first and third order absorption for both ZB and WZ QDs with and without wetting layer. It is shown that there is a slight difference between ZB and WZ in linear and nonlinear absorption while the ZB has a slightly bigger value. Figure 3(a) shows that linear absorption profile is mainly consists of on dominant peak, while as Figure 3(b) shows the third order nonlinear absorption consist of a valley and peak, and most surprisingly it has a comparable value to linear absorption. Also it consists of a peak and valley unlike the linear absorption which has only one peak. The presence of wetting layer causes the peak to happen in lower frequencies more ever always a remarkable escalation occurs in the peaks. It is worthwhile to mention that a second order susceptibility has no contribution on the absorption profile. (e.g. it is completely real hence there is no second order absorption)

Figure 4 shows the first, second and third order RRIC's for GaN/Aln QDs. Figure 4(a) shows that linear RRIC without wetting layer begins with 0.01 value while in presence of wetting layer it begins with almost 0.025. In the presence of wetting layer for both WZ and ZB structures the drop on the RRIC profile occurs in lower frequencies. However both curves come to steady state in same frequency. Figure 4(b) shows the RRIC due to second order nonlinear susceptibility. In presence of wetting layer the peak of second order RRIC takes almost 5 times larger than those without wetting layer. Figure 4(c) illustrates the third order RRIC which peculiarly has relatively stronger values in comparison to second order RRIC but is same order. Furthermore it is exhibited in Figure 4(c) that the RRIC has negative value initially and it rises to get a peak with positive value. In presence of wetting layer the RRIC is about 3.5 times larger than those of without wet-

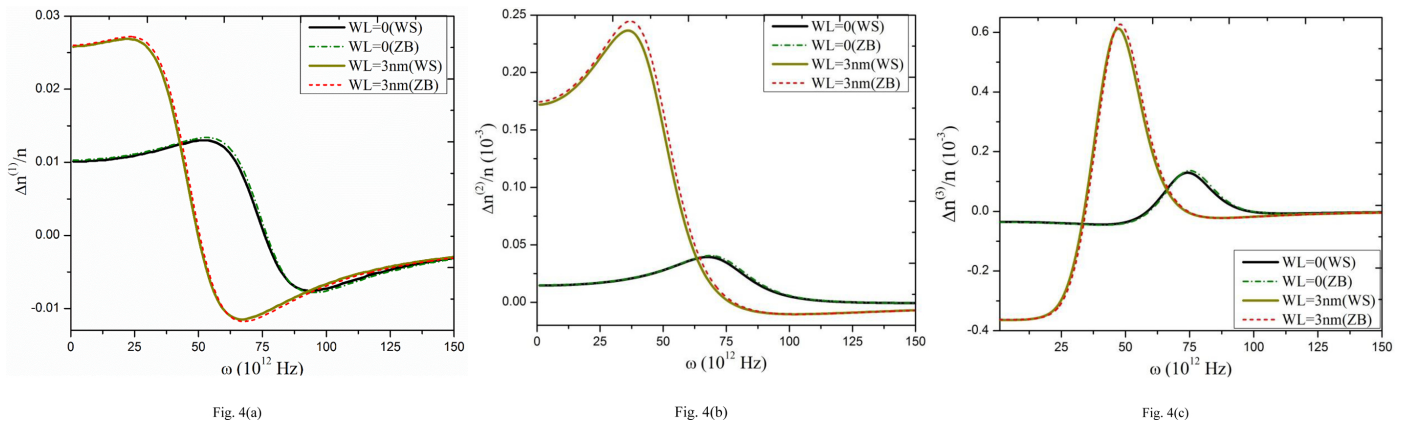


FIG. 4 The (a) first (b) second, and (c) third order relative refractive index changes for ZB and WZ GN/AlN QDs with (solid lines) and without wetting layer (dashed and dashdotted lines). The physical parameter set as Figure 3.

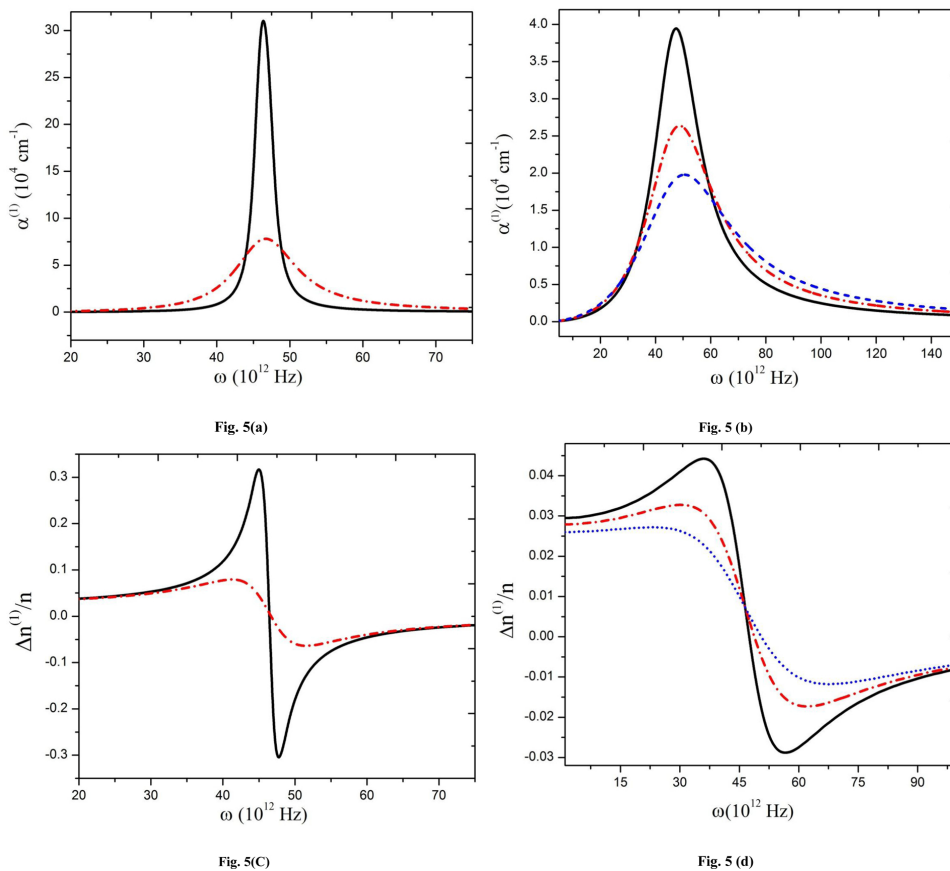


FIG. 5 The first order optical properties of truncated pyramids GaN/AlN QDs for variant relaxation rates with wetting layer (thickness = 3 nm). (a) First order absorption coefficient for  $\gamma = 1 \times 10^{12}$  (solid line),  $\gamma = 5 \times 10^{12}$  (dash-dotted line), and (b)  $\gamma = 10 \times 10^{12}$  (solid line),  $\gamma = 15 \times 10^{12}$  (dash-dotted line), and  $\gamma = 20 \times 10^{12}$  (dashed line), (c) first order relative refractive index changes for  $\gamma = 1 \times 10^{12}$  (solid line),  $\gamma = 5 \times 10^{12}$  (dash-dotted line), and (b)  $\gamma = 10 \times 10^{12}$  (solid line),  $\gamma = 15 \times 10^{12}$  (dash-dotted line), and  $\gamma = 20 \times 10^{12}$  (dashed line). Other physical parameters set as Figure 2.

ting layer. Additionally the third order RRIC never becomes zero and always has slight negative value; even in relatively big frequencies, while first and second order become zero.

As the result until now shows there is a narrow different between WZ and ZB structures in favor of ZB QDs. Henceforward we chose to provide the result for ZB structures in subsequent curves, by virtue of that the result are quite predictable for WZ structures.

Figure 5 shows the linear absorption and RRIC for different

amount of relaxation rates. In Figure 5(a),(c) for the aim of comparison, the  $\gamma$  set as  $1 \times 10^{12}$  (solid line) while it used to be  $5 \times 10^{12}$  (dashed line). It is obvious that by reducing the amplitude of  $\gamma$  to 1/5 the values of the peaks depict 6 times larger inflation. Figure 5(c) shows that the RRIC similarly shows comparatively prodigious escalation for both peaks and valleys. Then to interrogate the effect of relaxation more deeply, its amount varied for 3 other values as it is shown in Figure 5(b),(d). These curves clearly shows that by rising the amount of relaxation rate the overall profile decreases both for linear absorption coefficient and RRIC. Afterward we investi-

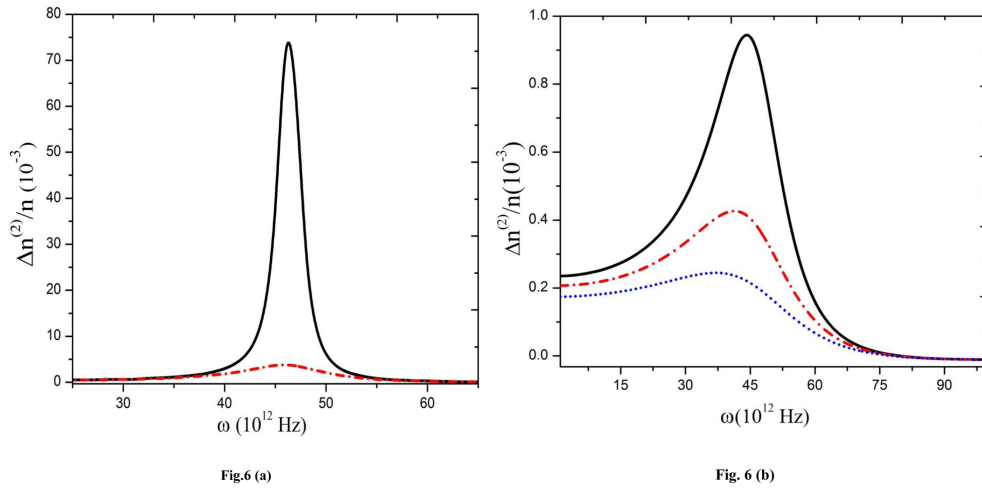


FIG. 6 Second order refractive index changes (RRIC) versus the field probe frequency for different amount of relation rates for GaN/AlN with wetting layer. (a) Second order RRIC for  $\gamma = 1 \times 10^{12}$  (solid line),  $\gamma = 5 \times 10^{12}$  (dash-dotted line), and (b)  $\gamma = 10 \times 10^{12}$  (solid line),  $\gamma = 15 \times 10^{12}$  (dash-dotted line), and  $\gamma = 20 \times 10^{12}$  (dotted line). The physical parameters set as Figure 2.

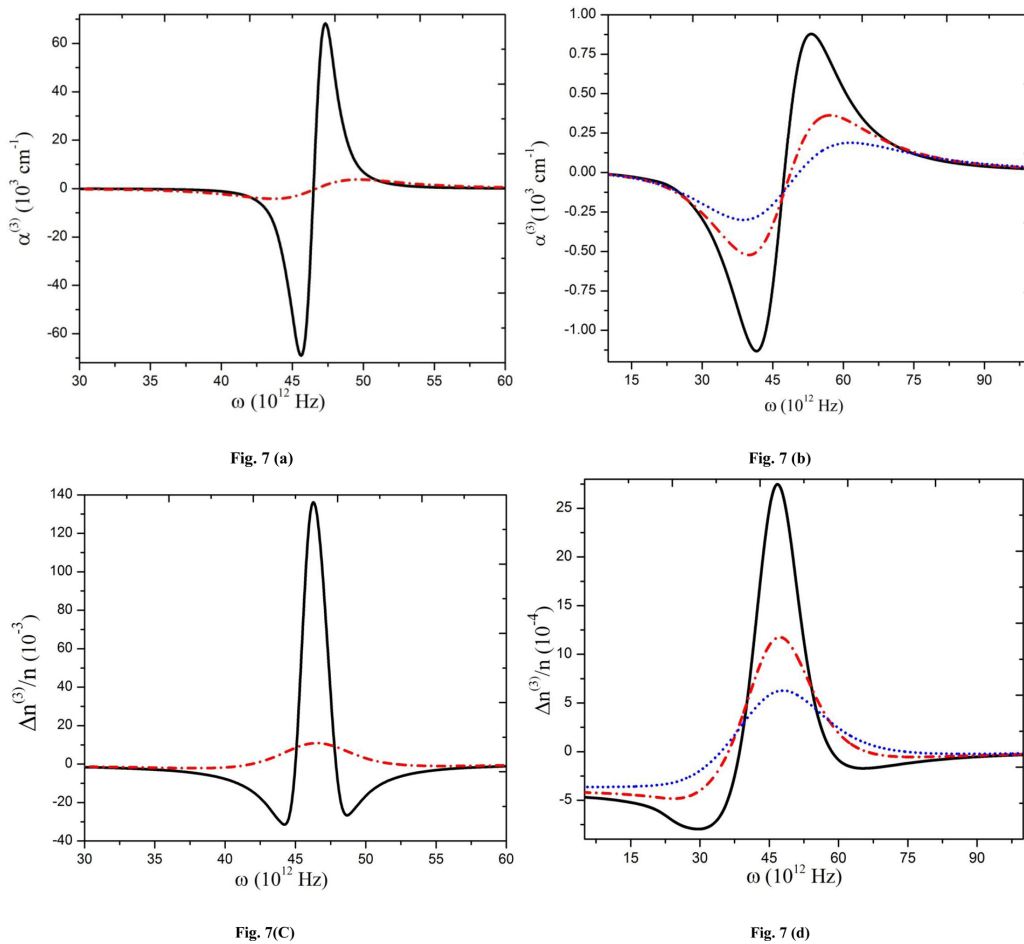


FIG. 7 The third order optical property truncated pyramids GaN/AlN QDs for variant relaxation rates with wetting layer (thickness = 3 nm). (a) First order absorption coefficient for  $\gamma = 1 \times 10^{12}$  (solid line),  $\gamma = 5 \times 10^{12}$  (dash-dotted line), and (b)  $\gamma = 10 \times 10^{12}$  (solid line),  $\gamma = 15 \times 10^{12}$  (dash-dotted line), and  $\gamma = 20 \times 10^{12}$  (dashed line), (c) first order relative refractive index changes for  $\gamma = 1 \times 10^{12}$  (solid line),  $\gamma = 5 \times 10^{12}$  (dash-dotted line), and (b)  $\gamma = 10 \times 10^{12}$  (solid line),  $\gamma = 15 \times 10^{12}$  (dash-dotted line), and  $\gamma = 20 \times 10^{12}$  (dashed line). Other physical parameters set as Figure 2.

gate the variation of RRIC due to second order susceptibility as it is shown in Figure 6. Figure 6(a) shows that reducing the amplitude of  $\gamma$  to  $1/5$ , the peak amplitude becomes about 60 times larger. Also as Figure 6(b) pageantries the effect of relaxation rate alteration is crucial however the bigger values remarkable decline take place. For instance the peak of RRIC

for  $\gamma/5$  (Figure 6(a)-solid line) is about 80 times stronger than those for  $2\gamma$  (Figure 6(b)-solid line).

Figure 7 shows the third order absorption coefficient and RRIC for discussed system under the variation of relaxation rates. Figure 7(a) shows that when we reduce the amplitude

of relaxation rate to  $\gamma/5$  the peak peaks of  $\alpha^3$  shows an escalation with about 300 times (solid line) in comparison to that belong to  $\gamma$  (dashed line). Similarly we applied same variation in relaxation rates for third order RRIC's. As Figure 7(c) shows the peak takes relatively 560 times larger amount for  $\gamma/5$ , which is significant and noticeable. Afterward we have examined difference amount of relaxation rates as Figure 7(b) (for AC's) and Figure 7(d) (for RRIC's) illustrates. The overall dramatic reduction in the amount of peaks is demonstrated for higher amount of relaxation rates as it is clearly shown in Figure 7(c),(d). However the FWHM which is bigger in smaller relaxation rates.

## 4 CONCLUSION

In this communication first of all we have discussed the modeling of GaN/AlN QDs. It is shown that the distribution of envelope function is affected by presence of wetting layer for all discussed subbands. Then by making use of numerical data we have calculated the linear and nonlinear optical properties of GaN/AlN QD. It is well demonstrated that there is a slight difference between the optical properties of WZ and ZB structures. It is well-proved that presence of wetting layer with 3 nm thickness causes around  $10 \times 10^{12}$  Hz movement in the position of peaks in all optical properties of GaN/AlN QDs as well as significant escalation on the amount of peaks. Eventually we change the amount of relaxation rates. The variation of relaxation rates profoundly influences the whole optical properties. Although when we changed the relaxation rates, it is found that there are specific frequencies that they never show any variation. By proper selection of physical properties of QDs it is possible to engineer the point with constant properties. The presented result shows that GaN/AlN QDs are marvelous candidates for future applications in optical optoelectronic devices.

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